



Chemical Concentration Monitor

Total Solution for Wet Process Monitoring

Conductivity
&
Resistance

HE-480C-GC

Carbon sensor conductivity meter

A highly chemical resistant sensor that is ideal for concentration control during process dilution control of chemicals and pure water recycling monitoring.



HE-480R (W)

Industrial resistivity meter

A resistivity meter that has a high precision temperature compensation ability and is ideal for continuous monitoring of ultrapure water.



Ozone
&
Hydrogen
Peroxide

HZ-960 Series

Dissolved ozone/ H2O2 monitor

Measures the dissolved ozone concentration of ozone water used in wet treatment processes of semiconductor devices. Ideal for measuring the concentration of hydrogen peroxide used for particle removal and impurity metal ion removal.

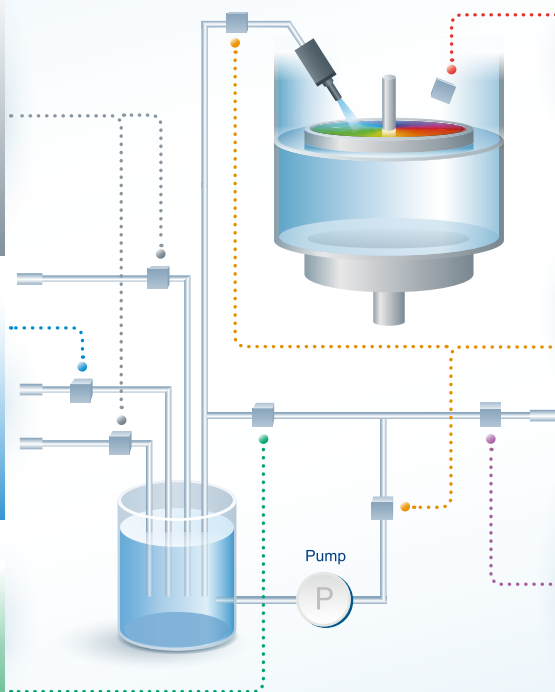


Dissolved
Oxygen

HD-960 Series

Dissolved oxygen concentration monitor

Ideal for measuring dissolved oxygen concentration in a liquid.



IT Series

Radiation thermometer



A small industry leading precision device with a built in radiation thermometer. Customizable measurement temperature, wavelength selection and visual field characteristics.
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Temperature

CS Series

Chemical Liquid concentration monitor



With strict chemical concentration control in the semiconductor manufacturing process a wide range of chemical concentration monitors are available.

Chemical
Concentration

HP-480

Chemical Liquid concentration monitor



From industrial waste water to monitoring manufacturing processes in various industrial fields and quality inspections HORIBA provides a wide range of services.

pH

UP-100

Trace sampling pH monitor



Continuous measurement of pH is possible with small sampling amounts of 500 U per measurement.